

Nanophotonics for telecom quantum networks based on neutral silicon vacancy centers in diamond

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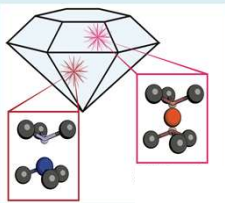
Requirements for quantum networks:

- Long lived quantum memory
- Efficient spin-photon interface
- Identical photons
- Telecom wavelength

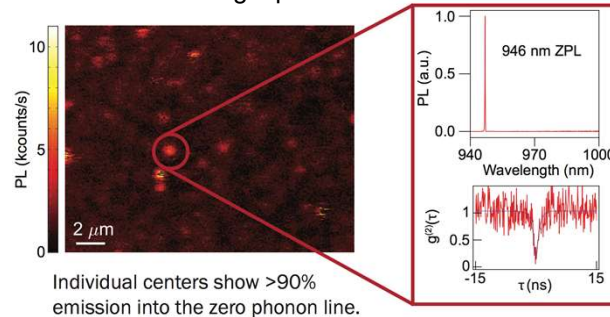


Prior work on color centers in diamond:

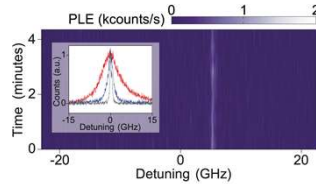
NV⁻ centers have long electron spin coherence, poor optical properties
SiV⁻ centers have better optical properties, poor spin coherence



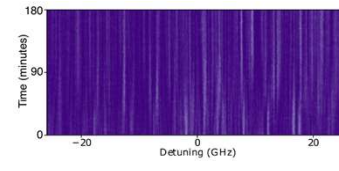
SiV⁰ is an excellent single photon source:



Near-transform-limited linewidth, low saturation power

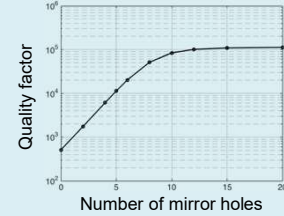
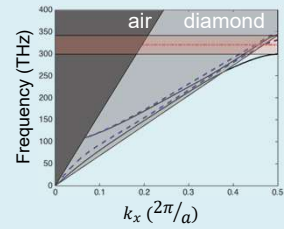
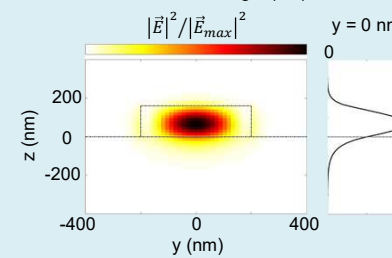
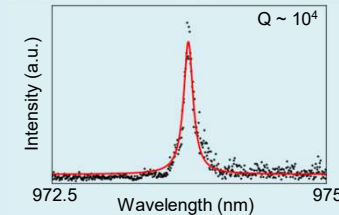
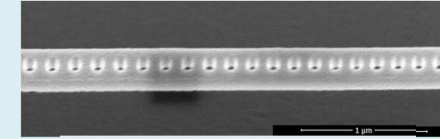


Ensemble PLE shows all centers have narrow lines over hours

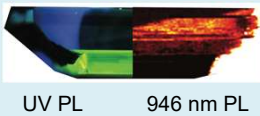


"Observation of an environmentally insensitive solid-state spin defect in diamond"
- Rose*, Huang*, et al, Science, 361, 60-63 (2018)

Photonic crystal cavity design



Neutral silicon vacancy centers

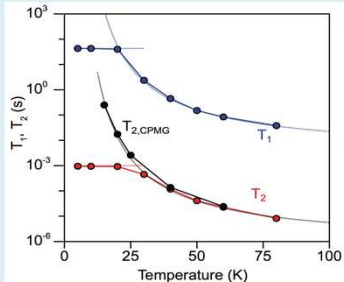


Key idea—Fermi level engineering to stabilize neutral charge state of SiV, access new spin configuration

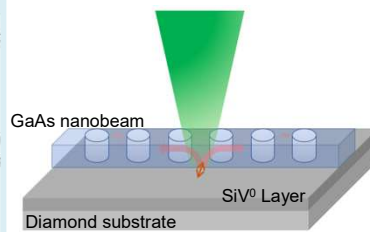
SiV⁰ is a long lived quantum memory:

$T_1 \sim 1$ minute

$T_2 \sim 1$ second



Heterogeneously integrated GaAs-on-diamond photonic platform



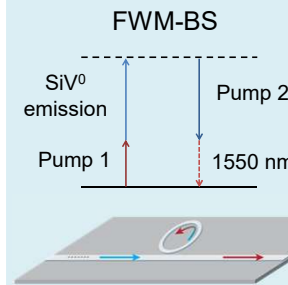
Collaboration with Jeff Thompson, Loren Pfeiffer

946 nm optical emission allows for use of GaAs, a mature photonic platform

Evanescent coupling to SiV⁰ in diamond substrate

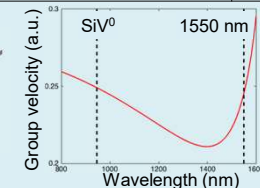
Fully integrated nanophotonic circuit using GaAs-on-diamond

On-chip quantum frequency conversion scheme



3 dB attenuation distance in single mode fibers

Material	Wavelength (nm)	Attenuation Distance (m)
Yb ⁺ ions	370 nm	< 50 m
NV ⁻ center	637 nm	300 m
SiV ⁻ center	737 nm	520 m
Rb atom	780 nm	750 m
SiV ⁰ center & QDs	~946 nm	1.5 km
Telecom C-band	1550 nm	15 km



Experiments with other material platforms:
Srinivasan group, Nat. Photonics, 2016 (SiN); Radic group, PRL, 2010 (SiO₂)